

**Amendments to the Claims:**

This listing of claims will replace all prior versions, and listings, of claims, including those in the First Preliminary Amendment, in the application:

**Listing of Claims:**

Claim 1 (previously presented – Article 19): A Ni-Pt alloy superior in workability containing Pt in a content of 0.1 to 20wt% and having a Vickers hardness of 40 to 90.

Claim 2 (previously presented – Article 19): The Ni-Pt alloy according to claim 1 having a purity of 99.99% or higher.

Claim 3 (currently amended): A ~~manufacturing~~ method of manufacturing Ni-Pt alloy superior in workability, comprising the steps of:

subjecting a raw material Ni having a purity of 3N level to electrochemical dissolution,

~~a step of~~ neutralizing the electrolytically leached solution with ammonia,

~~a step of~~ removing impurities by filtering the neutralized solution with activated carbon,

~~a step of~~ blowing carbon dioxide into the resultant solution to form nickel carbonate and exposing the resultant product to a reducing atmosphere to prepare high purity Ni powder,

~~a step of~~ leaching a raw material Pt having a purity of 3N level with acid,

~~a step of~~ subjecting the leached solution to electrolysis to prepare high purity electrodeposited Pt, and

a step of dissolving the resultant high purity Ni powder and high purity electrodeposited Pt.

Claim 4 (currently amended): The ~~manufacturing~~ method of Ni-Pt alloy according to claim 3, wherein the Ni-Pt alloy has a purity of 99.99% or higher.

Claims 5-6 (canceled).

Claim 7 (previously presented – Article 19): A Ni-Pt alloy target superior in workability containing Pt in a content of 0.1 to 20wt% and having a Vickers hardness of 40 to 90.

Claim 8 (previously presented – Article 19): The Ni-Pt alloy target according to claim 7 having a purity of 99.99% or higher.

Claim 9 (new): A method according to claim 4, wherein the Ni-Pt alloy has Pt in a content of 0.1 to 20wt% and has a Vickers hardness of 40 to 90.

Claim 10 (new): A method according to claim 9, further comprising the step of manufacturing a Ni-Pt alloy sputtering target from the high purity Ni powder and high purity electrodeposited Pt after said dissolving step.

Claim 11 (new): A method according to claim 3, wherein the Ni-Pt alloy has Pt in a content of 0.1 to 20wt% and has a Vickers hardness of 40 to 90.

Claim 12 (new): A method according to claim 11, further comprising the step of manufacturing a Ni-Pt alloy sputtering target from the high purity Ni powder and high purity electrodeposited Pt after said dissolving step.

Claim 13 (new): A method according to claim 3, further comprising the step of manufacturing a Ni-Pt alloy sputtering target from the high purity Ni powder and high purity electrodeposited Pt after said dissolving step.